

*Conductive  
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said insulating interlayer includes:

a first insulating layer of a composition containing SiH; and

a second insulating layer formed on said first insulating layer; and

a third insulating layer formed between said conductive film and said first insulating layer,  
said first insulating layer has an H content of not less than 15.4 atom% in the composition,  
and has been formed to cover said conductive film or the lower interconnection layer with the third  
insulating layer being interposed therebetween, and

said second insulating layer has a multilayer structure made up from layers of the same  
material